

IN THE CLAIMS:

Please amend claims 24, 26, 29 and 31 as follows:

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24. (Amended) A method of manufacturing a circuit board comprising a plurality of wiring patterns and a plurality of protrusions located at desired locations on the wiring patterns on a substrate, wherein said method comprises simultaneously and unitarily forming the wiring patterns and the protrusions.

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26. (Amended) The method of manufacturing a circuit board as defined in Claim 25 further comprising:

forming a first groove on a film, the first groove having a bottom surface;

forming a second groove at a predetermined location in the first groove;

filling conductive material into the first and the second grooves;

transferring the filled conductive material to the board; and firing the transferred conductive material.

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29. (Amended) A method of manufacturing a semiconductor device comprising:

- (a) simultaneously and unitarily forming a first plurality of wiring patterns and a second plurality of protrusions at desired locations on the wiring patterns on a circuit board; and
(b) coupling electrically the protrusions on said circuit board and electrodes on a semiconductor chip component.

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31. (Amended) The method of manufacturing a semiconductor device as defined in Claim 30 wherein forming the wiring patterns and the protrusions of the same conductive material comprises:

- forming a first groove on a film, the first groove having a bottom surface;
forming a second groove at a predetermined location in the first groove;
filling conductive material into the first and the second grooves;
transferring the filled conductive material onto the circuit board; and
firing the transferred conductive material.